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FACSIMILE TRANSMISSION

August 13, 2004

[062002-1751]**TO**

Parvis Hassanzadeh

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(Message) Examiner Hassanzadeh, this is transmission 3 of 5.

Number of Pages (Including This Cover Sheet): - 28 - Page(s)
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I hereby certify that this correspondence is being transmitted by facsimile to:

ATTN: Parvis Hassanzadeh
Facsimile number: 571 273 1435
Commissioner for Patents
P.O. Box 1450
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on August 13, 2004.


Eric Ringer

In re application of:	Kevin P. Martin et al.	Confirmation No.: 1603
U.S. Serial Number:	09/855,972	Art Unit: 1763
Filing Date:	May 15, 2001	Examiner: Hassanzadeh, Parvis
Our Reference Number:	62002-1751	

Title: Method and Apparatus for Low Energy Electron Enhanced Etching or Substrates in an AC or DC Plasma Environment

5 Cited References (Articles Only)